

## YAYASAN PENDIDIKAN DAYANG SUMBI INSTITUT TEKNOLOGI NASIONAL

## LEMBAGA PENELITIAN DAN PENGABDIAN KEPADA MASYARAKAT

Js PHH Mustapa 23: Bandung 40124 Indonesia, Telapon: +62-22-7272215 ext 157, Fax:022-720 2892 Web-site: Milp://www.itenap.ac.id., e-mail: lop@ifenas.ac.id

## SURAT KETERANGAN

## MELAKUKAN KEGIATAN PENGABDIAN KEPADA MASYARAKAT INSTITUT TEKNOLOGI NASIONAL No. 539/C.02.01/LP2M/VIII/2018

Yang bertanda tangan di bawah ini,

Nama

: Dr. Tarsisius Kristyadi, S.T., M.T.

Jabatan

: Kepala

Unit Kerja

: LP2M-Itenas

JL. P.K.H. Mustafa No.23 Bandung

Menerangkan bahwa,

Nama	NPP	Jabatan
Dicky Dermawan, S.T., M.T.	960603	Technical Advisor

Telah melakukan kegiatan Pengabdian kepada Masyarakat sebagai berikut :

Nama Kegiatan

Pengembangan Produk Resain Adhesive

Tempat

PT. Dover Chemical

Waktu

24 - 27 Juli 2018

Sumber Dana

PT. Dover Chemical

Demikian surat keterangan ini dibuat untuk dapat dipergunakan sebagaimana mestinya.

Bandung, 07 Agustus 2018

Lembaga Penelitian dan Pengabdian kepada Masyarakat (LP2M) Itenas

Kepala,

Dr. Tarsisius Kristyadi, S.T., M.T.

NPP 960604

## PT. DOVER CHEMICAL

Jl. Raya Merak Km. 117, Desa Gerem Kec, Grogol Kota Cilegon 42438 Banten - Indonesia

> Tel: (62-254) 571064 Fax: (62-254) 571224 www.dovechem.co.id

## SURAT KETERANGAN

Yang bertanda tangan di bawah ini,

Nama : Dr. H. Dade Suparna, SH.,MH

Jabatan : HR & GA Manager

Alamat Jl. Raya Merak KM.117 Ds. Gerem, Kec. Grogol

Kota Cilegon - Banten 42438

Menerangkan bahwa:

Nama : Dicky Dermawan

Jabatan : Dosen Program Studi Teknik Kimia Itenas

Alamat : Jl. PHH. Mustafa 23 Bandung 40124

Telah melakukan kegiatan sebagai Technical Advisor pada :

Judul : Studi Pengembangan Produk Resin Adhesive untuk Industri Panel Kayu

Tempat : Production & Development Unit PT. Dover Chemical

Jl. Raya Merak KM,117 Ds. Gerem, Grogol, Kota Cilegon Banten 42438

Waktu : 24 - 26 Juli 2018

Berdasarkan Nota Kesepahaman antara Jurusan Teknik Kimia Institut Teknologi Nasional (Itenas) dengan PT. Dover Chemical tanggal tiga puluh bulan Januari tahun dua ribu tujuh belas.

Demikian surat keterangan ini dibuat untuk dapat digunakan sebagaimana mestinya.

over Chemical

Cilegon, 26 Juli 2018

Dr. H. Dade Suparna, SH.,MH

HR & GA Manager









## YAYASAN PENDIDIKAN DAYANG SUMBI INSTITUT TEKNOLOGI NASIONAL

## LEMBAGA PENELITIAN DAN PENGABDIAN KEPADA MASYARAKAT

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## SURAT TUGAS No. 460/J.16.01/LP2M/VII/2018

## Yang bertanda tangan dibawah ini,

Nama

: Dr. Tarsisius Kristyadi, S.T., M.T.

labatan

: Kepala

Unit Kerja

: LP2M-ITENAS

JL. PHH Mustafa No. 23 Bandung

## Menerangkan bahwa:

Nama	NPP	Jabatan
Dicky Dermawan, S.T., M.T.	960603	Dosen

## Ditugaskan untuk melakukan,

Kegiatan

: Pengembangan Produk Resain Adhesive

Sebagai

: Technical Advisor

Tempat

: PT. Dover Chemical

Jalan Raya Merak Km. 117 Cilegon, Banten

Hari/Tanggal : Selasa-Kamis/24-26 Juli 2018

Demikian surat tugas ini dibuat untuk dipergunakan sebagaimana mestinya.

Bandung, 16 Juli 2018

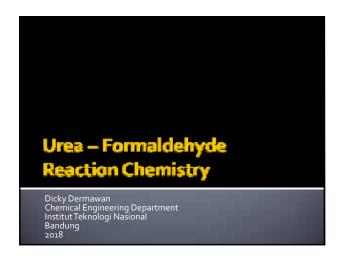
Lembaga Penelitian dan Pengabdian kepada Masyarakat (LP2M) Itenas

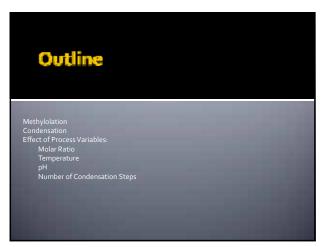
Kepala,

Dr. Tarsisius Kristyadi, S.T., M.T. NPP. 960604

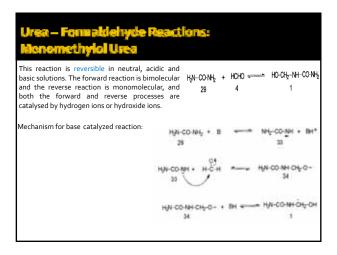
## Tembusan Yth:

- Dekan FTI
- KaJur Teknik Kimia
- Kepala Kepegawaian

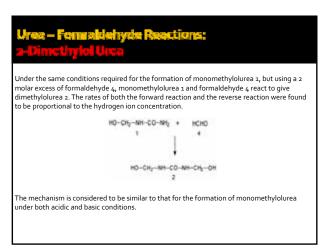




# This reaction is reversible in neutral, acidic and basic solutions. The forward reaction is bimolecular and the reverse reaction is monomolecular, and both the forward and reverse processes are catalysed by hydrogen ions or hydroxide ions. Mechanism for acid catalyzed reaction:



## This reaction is reversible in neutral, acidic and basic solutions. The forward reaction is bimolecular and the reverse reaction is monomolecular, and both the forward and reverse processes are catalysed by hydrogen ions or hydroxide ions. Alternative mechanism: The formation of methylene glycol in aqueous solution, however, has prompted the suggestion that the condensation involves a direct displacement reaction between urea and methylene glycol



## The involvement of methanol

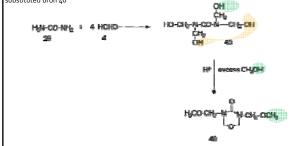
Other products obtained in urea-formaldehyde reactions include:- the methyl ether 47 of monomethylolurea; dimethylolurea monomethyl ether 48; dimethylolurea dimethylether 49; monomethylolmethylenediurea 50; monomethylolmethylenediurea methyl ether 51; dimethylolmethylenediurea monomethyl ether 52; dimethylolmethylene diurea 53 and dimethylolmethylenediurea dimethylether 54

Compound	Structure
47	#NOSBOLOGE
48	HO-CH, NIE-CO-NIE-CH, 45-CH,
29	H.C.OCH-SHICO-SHICH-OCIL
50	нуксомиснумисомиси-он
11	IIX COSB-CH-80 COSB-CH-OCH
52	HO-CH, WHICO-SHICH, SHICO-SHICH, G-CH,
53	HO-CH_NIECG-SIECH_SIECG-SIECU_OH
54	n.cocusii.cosii:cusii.cosii:cu;ocii.

At high temperatures, trimethylolurea 44 is known to form; in this product, three of the urea amide hydrogens have been replaced by methylol groups.

Of course, urea has four reactive hydrogens, but the first three are more readily replaced than the fourth. Under strongly basic conditions and at 60 °C, the fourth hydrogen may be lost with the formation of tetrasubstituted ureas.

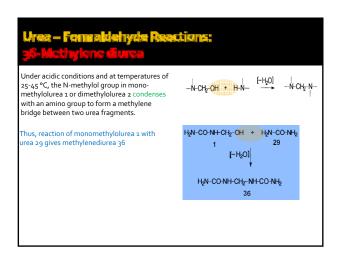
## The treatment of tetramethylolurea 45 with excess methanol, under acidic conditions at room temperature, results in rearrangement and methylation of the hydroxyl groups to form the substituted uron 46

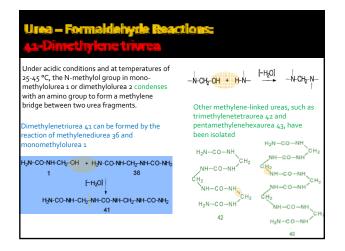


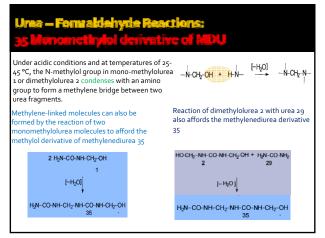
## Urea – Fannaklehyde Reactions: Formation of ethylene ether linkage Under basic conditions The formaldehyde emitted during the hot cure can partly be traced back to the substances containing methylene ether linkages. When subjected to heat, these ether bridges will decompose through hydrolysis and form formaldehyde.[6] The free formaldehyde emitted from aging UF resins is believed to be a result of that molecules containing for example

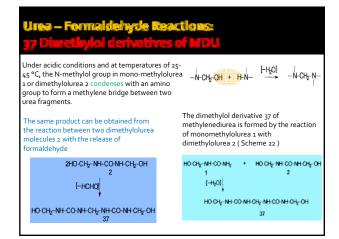
methylol gropus and dimethyl ether bridges will decompose through hydrolysis, and thus form The styribe groups and unitedly cluster brings an account of the substances containing the methylene ether linkages. This includes the above mentioned methods of varying the different reaction parameters, such as: pH, reaction temperature, reaction time, formaldehyde/urea molar ratio and number of condensation steps.

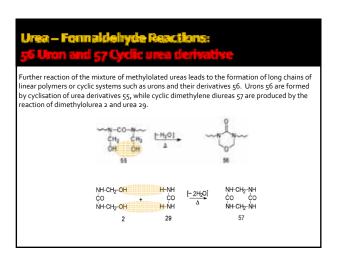
## Under acidic conditions and at temperatures of 25-45 °C, the N-methylol group in mono-methylolurea 1 or dimethylolurea 2 condenses with an amino group to form a methylene bridge between two urea fragments. Reaction mechanism for this: жсңон + на — - - - но + но + аг зв зв

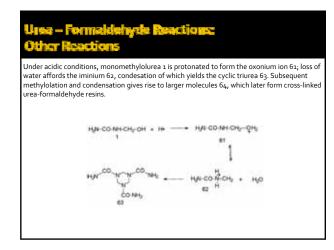


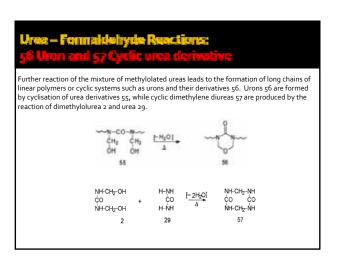


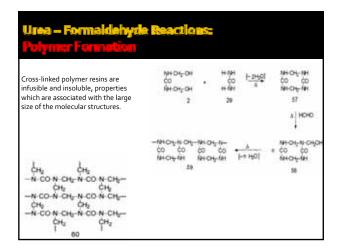


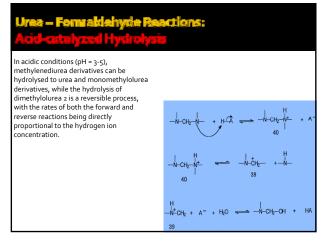


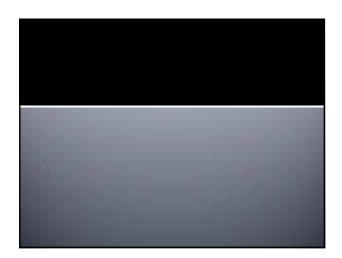


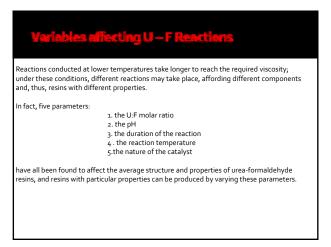


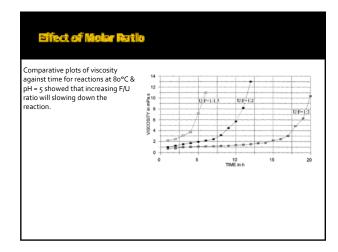


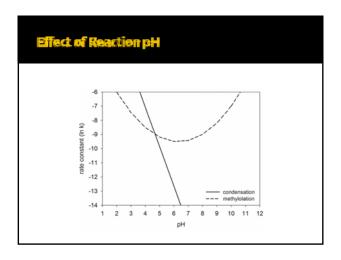












## Effect of Reaction pH

Different types of UF dimers will be formed at different pH values. The dimers formed will have an impact on the properties of the finished adhesive, e.g. the formaldehyde emissions can be controlled by controlling the composition of dimers.

UF dimers with methylene linkages are formed if the pH during condensation is kept at 8 or less. Additionally, it was also shown that methylene linkages are favored by a decrease in pH. The formation of UF dimers with ether linkages had a minimum yield point at pH 8. At either side of that value, independently of if the pH value is increased or decreased, the formation of ether linkages increased.

At pH 6.5-7.5, both of the substances containing methylene linkages and ether linkages were formed to the same extent.

At pH 6 or less, however, ether linkages were formed in the favor of methylene linkages. This was explained by that the methylolation of the urea was slower than at higher pH values. As a consequence, unsubstituted amino groups will remain to a larger extent, which favors the formation of methylene linkages.

## Effect of Reaction Temperature

Secara umum makin tinggi suhu reaksi makin cepat lah....

The effect of the reaction temperature has on the synthesis is dependent on the pH value of the reaction mixture, where these temperature alternations occur. Temperature variations were studied at both pH 7.0 and 8.5. The temperatures chosen were 60, 70 and 8.6°C

The temperature had no impact on the substitution reaction between urea and formaldehyde at pH 8.5, but an increase in amount of substituted urea was observed at pH 7. The amount of condensed di- and triureas was also increased with temperature; however the rate of hydrolysis was also increased with temperature.

The most pronounced effect of the reaction temperature was displayed at pH 7. At pH 7 the amount of substances larger than diureas, were increased from 9% to 55% by increasing the temperature from 60 to 80°C.

## Effect of Catalyst Type

Not solely depending on reaction pH, the type of acid and base used results in different product properties.

## Effect of Number of Urea Addition Step

The number of condensation steps and the duration of these has an effect on the molecular structure of the resin, and thus also upon its inherent properties, such as molecular weight. When urea is added, it will break some of the bonds already formed between different UF monomers. The urea will then react with the newly released formaldehyde to form methylol ureas. As the number of urea steps is increased, more urea will be added that breaks up the larger structures and, as a consequence, the reaction mixture becomes more homogenous. This means that if the number of condensation steps is increased, the polydispersity index (PDI) is decreased.

PDI is an important factor when considering adhesives. This is due to that different sizes of molecules have different roles to play when it comes to the adhesive property of the resin Smaller molecules are better at wetting the surface enables a good adhesion. The larger molecules, on the other hand, have the ability to form entanglements with other polymeric chains. These entanglements ensure that the cohesion is strong enough for the adhesive molecules to hold together. Cohesion is the ability for identical or similar molecules to hold together. By combining good cohesive and adhesive properties an adhesive can adhere well to the two substrate surfaces, and at the same time have sufficient strength within the glue line. A sufficiently high PD would, therefore, ensure a good combination between adhesive and cohesive ability, which in turn ensures good adhesion.

## Effect of Number of Urea Addition Step

Formaldehyde emissions are also affected by the number and duration of condensations steps. The emissions of formaldehyde were lower with increasing number of condensation steps, and increasing duration for which they took place.

The decrease in formaldehyde emissions as a consequence of an increase in condensation steps might be explained by that when the numbers of condensations were increased, the F/U molar ratio decreased in each step. This means that the number of methylol groups added per urea molecule would be fewer and fewer for each step. The added urea would also break apart the larger structure. The methylol groups on these structures as well as on the newly formed methylol ureas would then have a greater chance of reacting with an amino group instead of another methylol group. Consequently, this will generate more methyl linkages and fewer ether linkages which might result in lower formaldehyde emissions.

## Effect of Fixel FSU Moler Ratio in Typical Alicellas – Acid Process

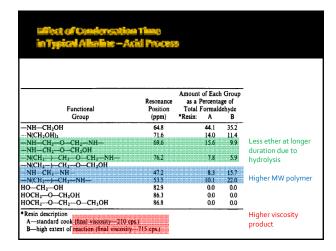
Functional	Resonance Position	as a	t of Each Percenta Formale	ge of
Group	(ppm)	*Resin: A	В	C
—NH—CH₂OH	64.8	44.1	50.6	36.6
-N(CH <sub>2</sub> OH) <sub>2</sub>	71.6	14.0	10.4	13.4
-NH-CH2-O-CH2-NH-	69.6	15.6	13.7	17.1
-NH-CH₂-O-CH₂OH				
N(CH <sub>2</sub> )CH <sub>2</sub> OCH <sub>2</sub> NH	76.2	7.8	5.7	9.6
N(CH <sub>2</sub> )CH <sub>2</sub> OCH <sub>2</sub> OH				
-NH-CH2-NH-	47.2	8.3	8.1	6.6
N(CH₂)CH₂NH	53.5	10.1	10.7	11.5
НО—СН₂—ОН	82.9	0.0	1.0	5.1
НОСН₂—О—СН₂ОН	86.3	0.0	0.0	0.0
HOCH2-O-CH2-O-CH2OH	86.8	0.0	0.0	0.0

Resin description
A—1.1 MR (standard cook)
B—1.43 MR
C—2.0 MR

Free formaldehyde Linear vs branching

Functional	Resonance Position	as a	of Each Percenta Formald	ge of
Group	(ppm) *Resin		В	C
-NHCH₂OH	64.8	65.2	44.1	31.7
$-N(CH_2OH)_2$	71.6	5.4		
-NH-CH <sub>2</sub> -O-CH <sub>2</sub> -NH- -NH-CH <sub>2</sub> -O-CH <sub>2</sub> OH	69.6	13.8	15.6	20.4
-N(CH <sub>2</sub> )CH <sub>2</sub> OCH <sub>2</sub> NH -N(CH <sub>2</sub> )CH <sub>2</sub> OCH <sub>2</sub> OH	76.2	0.0	7.8	8.2
-NH-CH₂-NH-	47.2	10.9	8.3	19.2
-N(CH₂)CH₂NH	53.5	4.6	10.1	9.6
но—сн₂—он	82.9	0.0	0.0	0.0
HOCH <sub>2</sub> —O—CH <sub>2</sub> OH	86.3	0.0	0.0	0.0
HOCH2-O-CH2-O-CH2OH	86.8	0.0	0.0	0.0

in Typical Alkalius – A	dd Process			
Functional Group	Resonance Position (ppm)	Amount of Each as a Percenta Total Formald *Resin: A	ge of `	-
NHCH <sub>2</sub> OH N(CH <sub>2</sub> OH) <sub>2</sub>	64.8 71.6	24.1 2.2	31.7 10.7	-
-NH-CH <sub>2</sub> -O-CH <sub>2</sub> -NH- -NH-CH <sub>2</sub> -O-CH <sub>2</sub> OH	69.6	4.3	20.4	No selección de la latera
—N(CH <sub>2</sub> —) CH <sub>2</sub> O CH <sub>2</sub> NH —N(CH <sub>2</sub> —) CH <sub>2</sub> O CH <sub>2</sub> OH	76.2	0.0	8.2	No ether at too high
-NH-CH <sub>2</sub> -NH-	47.2	29.3	19.2	pH, possibly cause by
-N(CH <sub>2</sub> )CH <sub>2</sub> NH	53.5	12.0	9.6	hidrolysis at acid
HO—CH <sub>2</sub> —OH	82.9	0.0	0.0	condensation step
HOCH <sub>2</sub> —O—CH <sub>2</sub> OH	86.3	0.0	0.0	condensation step
HOCH <sub>2</sub> OCH <sub>2</sub> OCH <sub>2</sub> OH	86.8	0.0	0.0	
NH-CO-NH	74.8	11.1	0.0	Uron at high pH
CH <sub>2</sub> —O—CH <sub>2</sub>				
NH—CO—N—CH <sub>2</sub> OH	(1) 68.6	5.3	0.0	More methanol at
1 (1)	117 00.0		30010001000	
сн.—осн.	(2) 78.9	8.9	0.0	higher pH due to
(2)			seemeedCE!!	Cannizarro reaction



Functional Group	Resonance Position (ppm)	Amount of Each Group as a Percentage of Total Formaldehyde *Resin: A B			
-NHCH₂OH	64.8	44.1	83.5	Slower reaction at	
-N(CH₂OH)₂ -NHCH₂-OCH₂NH -NHCH₂-OCH₂OH	71.6 69.6	14.0 15.6	5.1 4.3	dilute concentration	
-N(CH <sub>1</sub> )CH <sub>1</sub> OCH <sub>1</sub> NH	76.2	7.8	0.0	Less ether linkage at	
−N(CH2−)−CH2−O−CH2OH −NH−CH2−NH−−	47.2	8.3	2.8	dilute concentration	
-N(CH;)CH;NH	53.5	10.1	0.0	anote concentration	
Ю—СН₃—ОН	82.9	0.0	1.2		
ЮСН₂—О—СН₂ОН	86.3	0.0	0.0		
łOCH₂—O—CH₂—O—CH₂OH	86.8	0.0	0.0		
NN-CO-NH	75.0	0.0	0.6	Uron formation at	
н, -о-сн,				dilute concentration	
NH—CO—N—CHIOH	(1) 68.4	0.0	1.0	unote concentration	
(I) (I)					
H,OCH,	(2) 78.8	0.0	1.2		
(2)					